

Diffusion and Interface Stability during Solid-State Displacement Reactions.

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Solid State Displacement Reaction: (Redox Reaction)



($\mathbf{A, B = metal ; X = non-metal.}$)

Product Phases:

$"B"$ → pure \mathbf{B} or $\mathbf{A-B}$ alloy.
 $"AX"$ → pure \mathbf{AX} or
 $(\mathbf{A,B})X$ solid solution or
 $(\mathbf{A}_a\mathbf{B}_b)\mathbf{X}_x$ compound.

Kinetic and Microstructural Control :

- Thermodynamics of product phases, “ \mathbf{B} ” and “ \mathbf{AX} ”
 - Solubility of \mathbf{X} in “ \mathbf{B} ”, if any.
 - Point defect chemistry of “ \mathbf{AX} ”
- * Diffusion in product phases, “ \mathbf{B} ” and “ \mathbf{AX} ”

Displacement Reaction between a metal and an oxide:



Product Phases, A (metal) and BO (oxide) :

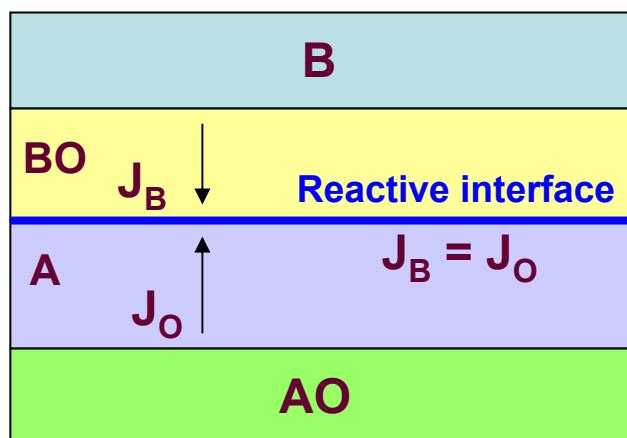
A – Significant Solubility, $N_O(A)$ and Diffusivity, $D_O(A)$ of Oxygen.

-- Flux $J_O(A)$ contributes to kinetics.

BO – Point defects in *Cation sublattice* only.

-- Flux $J_B(BO)$ contributes to kinetics.

-- *Oxygen is essentially immobile* { $D_B(BO) >> D_O(BO)$ }



Two Limiting Cases:

(i) $J_B(BO)$ is rate limiting.

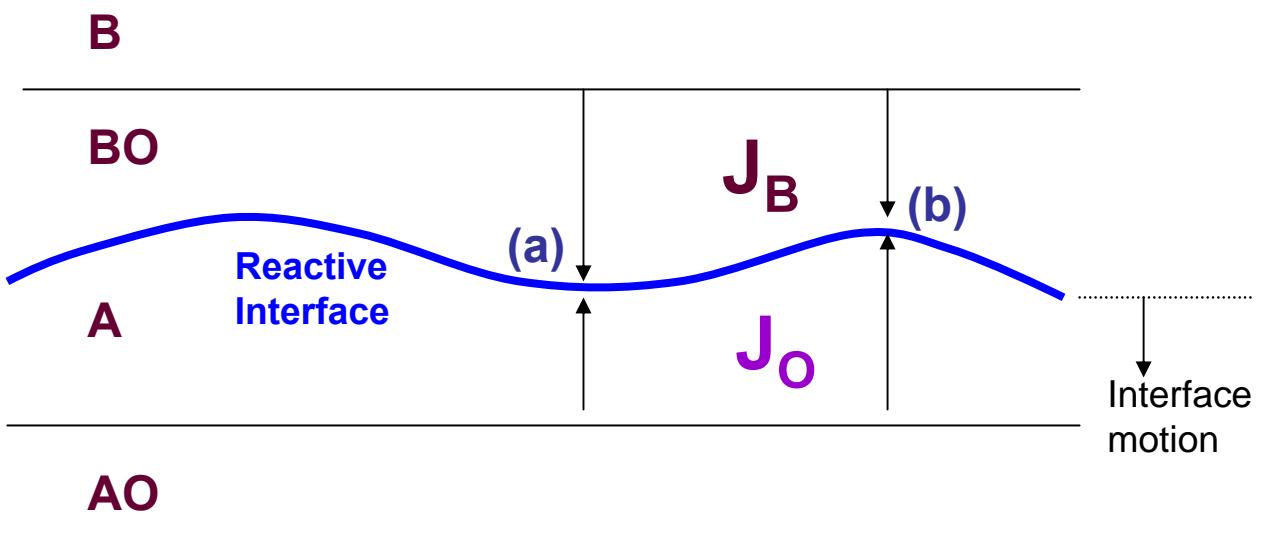
(ii) $J_O(A)$ is rate limiting.

Ref : R.A.Rapp, A.Ezis and G.J.Yurek

Metallurgical Transactions, 4 , 1973, pp. 1283-92

- Stability of Reactive Interface.
- Product Zone Microstructure.

Stability of Reactive Interface -- C. Wagner's Criterion :



Limiting Cases:

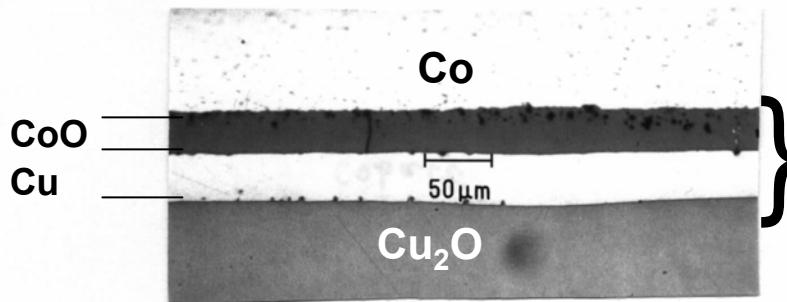
Case (i) : $J_B (\text{BO})$ is rate limiting.

J_B at location (b) > J_B at location (a)
⇒ Interface becomes **planar** with time.

Case (ii): $J_O (\text{A})$ is rate limiting.

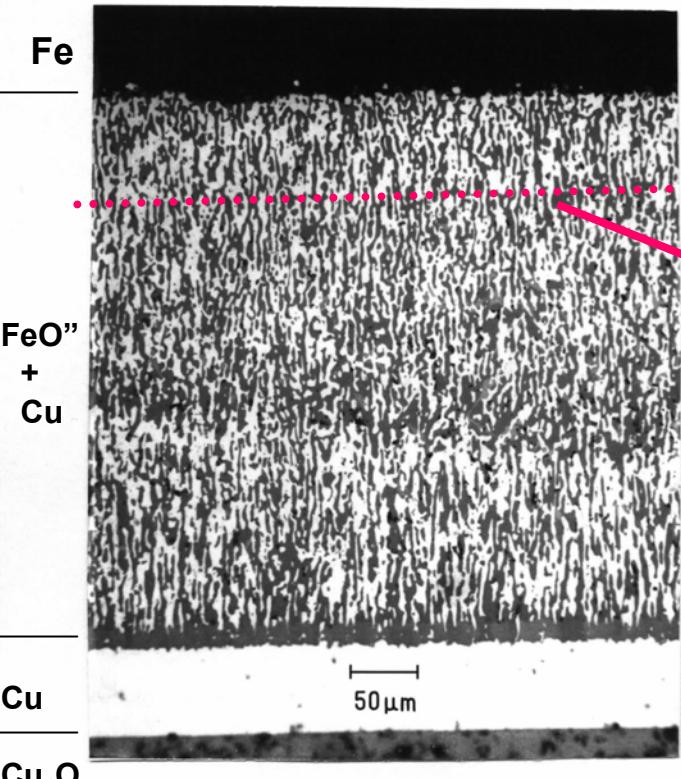
J_O at location (a) > J_O at location (b)
⇒ Interface **instability** increases with time.

Reactive interface is morphologically unstable when it moves against the flux of the rate determining component H. Schmalzried, Chemical Kinetics of Solids, VCH Weinheim, 1995



Reaction:
 $\text{Cu}_2\text{O} + \text{Co} = 2\text{Cu} + \text{CoO}$

Rate Control: $J_{\text{Co}}(\text{CoO})$



(a)



(b)

Reaction: $\text{Cu}_2\text{O} + \text{Fe} = 2 \text{Cu} + \text{“FeO”}$

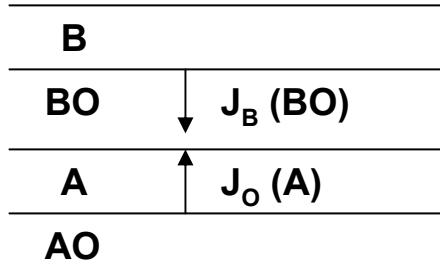
(a) Cross-sectional view ; (b) transverse view

Rate Control: $J_{\text{O}}(\text{Cu})$

(bright phase: metal ; dark phase: Oxide)

(Reproduction of work by Rapp, Ezis and Yurek at 1223 K)

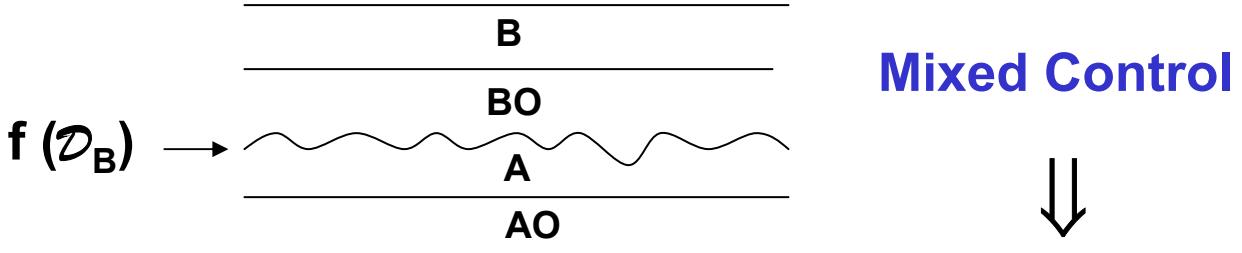
Interface Stability as a function of \mathcal{D}_B in BO :



Rate Control : $J_B (BO)$
(examples: Cu_2O/Ni or Co)

* Maintain constant $N_O (A)$ and $\mathcal{D}_O (A)$

• Increase $\mathcal{D}_B (BO)$ → ↓



Rate Control : $J_O (A)$
(unstable interface)

Strategy:



(D = “dopant”)

Dopant function : $N_V \text{ in } (B,D)O > N_V \text{ in } (BO)$
 $\mathcal{D}_B (B,D)O > \mathcal{D}_B (BO)$

(N_V = Cation Vacancy concentration)

Doping Mechanism to increase N_V in (B,D)O :

(a) Charge compensation: (Valence of D > Valence of B)

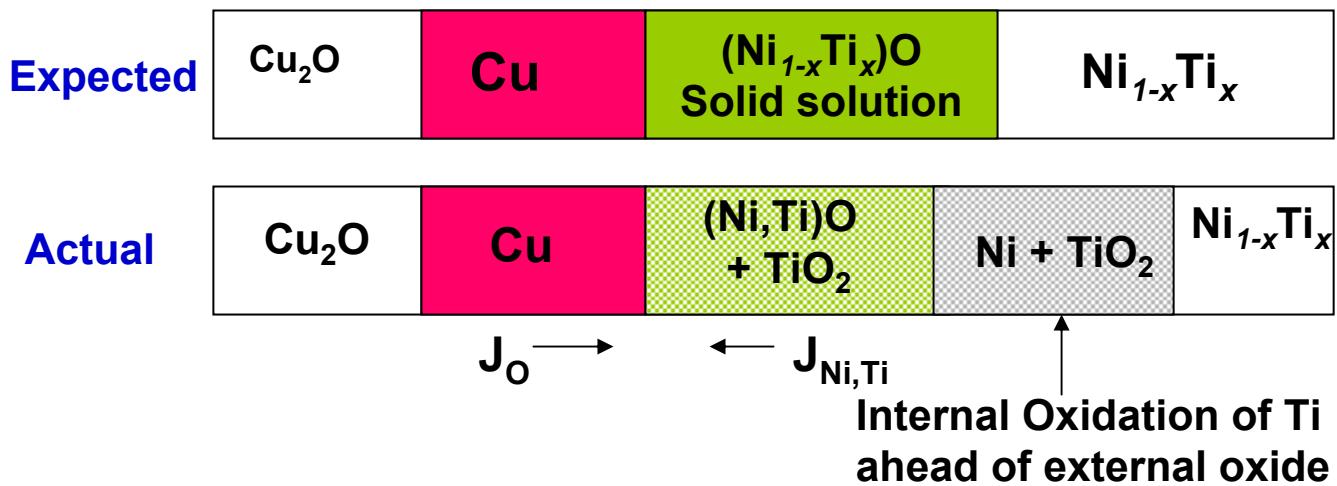
e.g, $\text{Cu}_2\text{O} + (\text{Ni}_{1-x}\text{Ti}_x) = 2 \text{ Cu} + (\text{Ni}_{1-x}\text{Ti}_x)\text{O}$ (solid solution)

$$(x = 0.001 - 0.05)$$



$$\Rightarrow N_\text{V} = N_{\text{Ti}} = x \neq f(p_{\text{O}_2}, T)$$

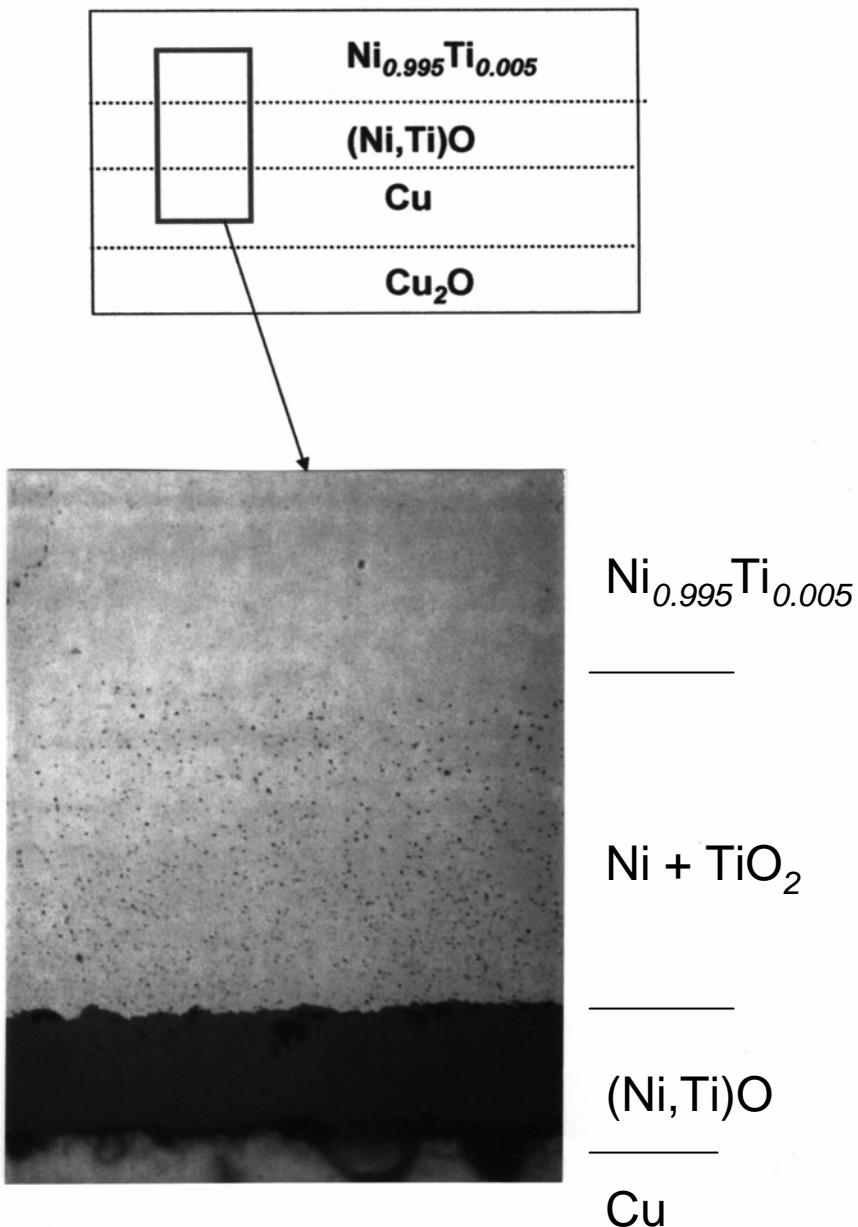
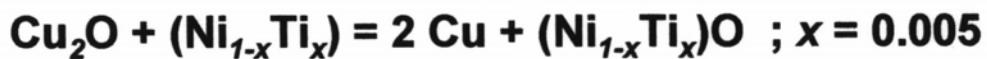
Assumption: Homogenous (Ni,Ti)O solid solution.



Consequence of Internal Oxidation:

- Inhomogenous (Ni,Ti)O phase.
- $N_{\text{Ti}} (= N_\text{V}) < x$ in (Ni,Ti)O oxide solid solution.
- Rate control transition, $J_{\text{Ni}} (\text{Ni},\text{Ti})\text{O} \rightarrow J_\text{O} (\text{Cu})$ was not possible.

Reaction:



Product zone microstructure for the reaction between Cu_2O and (Ni,Ti) alloy.

Doping mechanism to increase N_V:

(b) Increase in non-stoichiometry of product oxide, (B,D)O:

Non-stoichiometry reaction: $\frac{1}{2} \text{O}_2(\text{g}) = \text{O}_{\text{O}}^x + \text{V}_{\text{B}}$

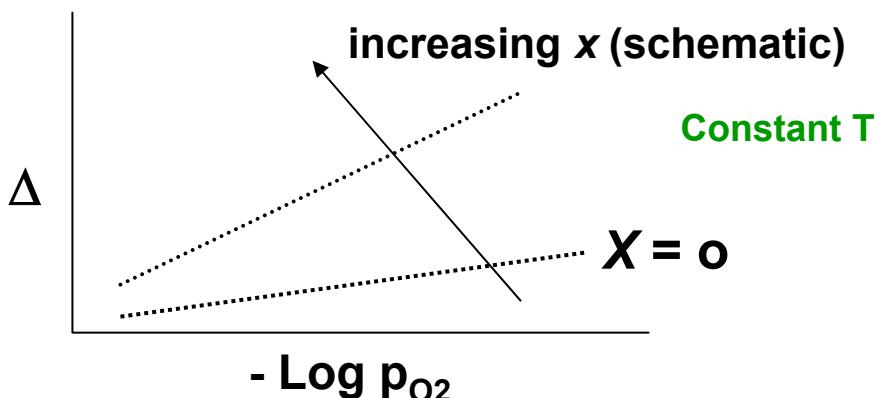
$\Rightarrow \text{B}_{1-\Delta}\text{O}$ and $(\text{B}_{1-x}\text{D}_x)_{1-\Delta}\text{O}$; $N_V \propto \Delta$

Δ in (B,D)O > Δ in BO

$\Rightarrow N_V = f(N_D, p_{\text{O}_2}, T)$

Example: $\text{Cu}_2\text{O} + (\text{Co}_{1-x}\text{Fe}_x)\text{O} = 2 \text{Cu} + (\text{Co}_{1-x}\text{Fe}_{1-x})_{1-\Delta}\text{O}$

Cu_2O	Cu	$(\text{Co}_{1-x}\text{Fe}_x)\text{O}$	$\text{Co}_{1-x}\text{Fe}_x$
	$\longrightarrow J_O$	$\longleftarrow J_{\text{Co},\text{Fe}}$	



Ref: Aukrust, Muan, 1964

Subramanian, Tinkler, Dieckmann, 1994

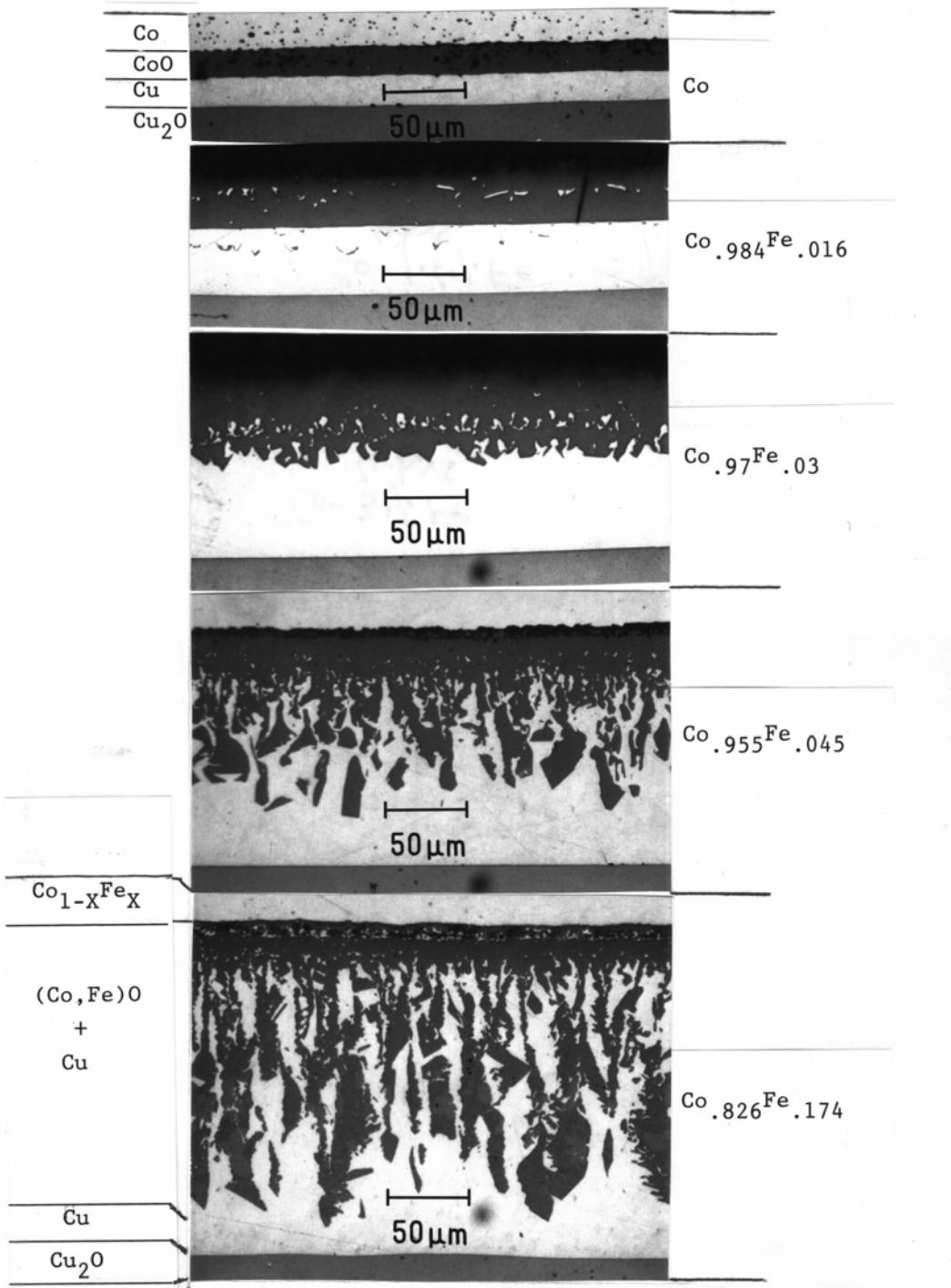


Fig. Displacement reaction between Cu₂O and Co_{1-X}Fe_X alloys at 1223K. Product phase morphology after 4 hours.

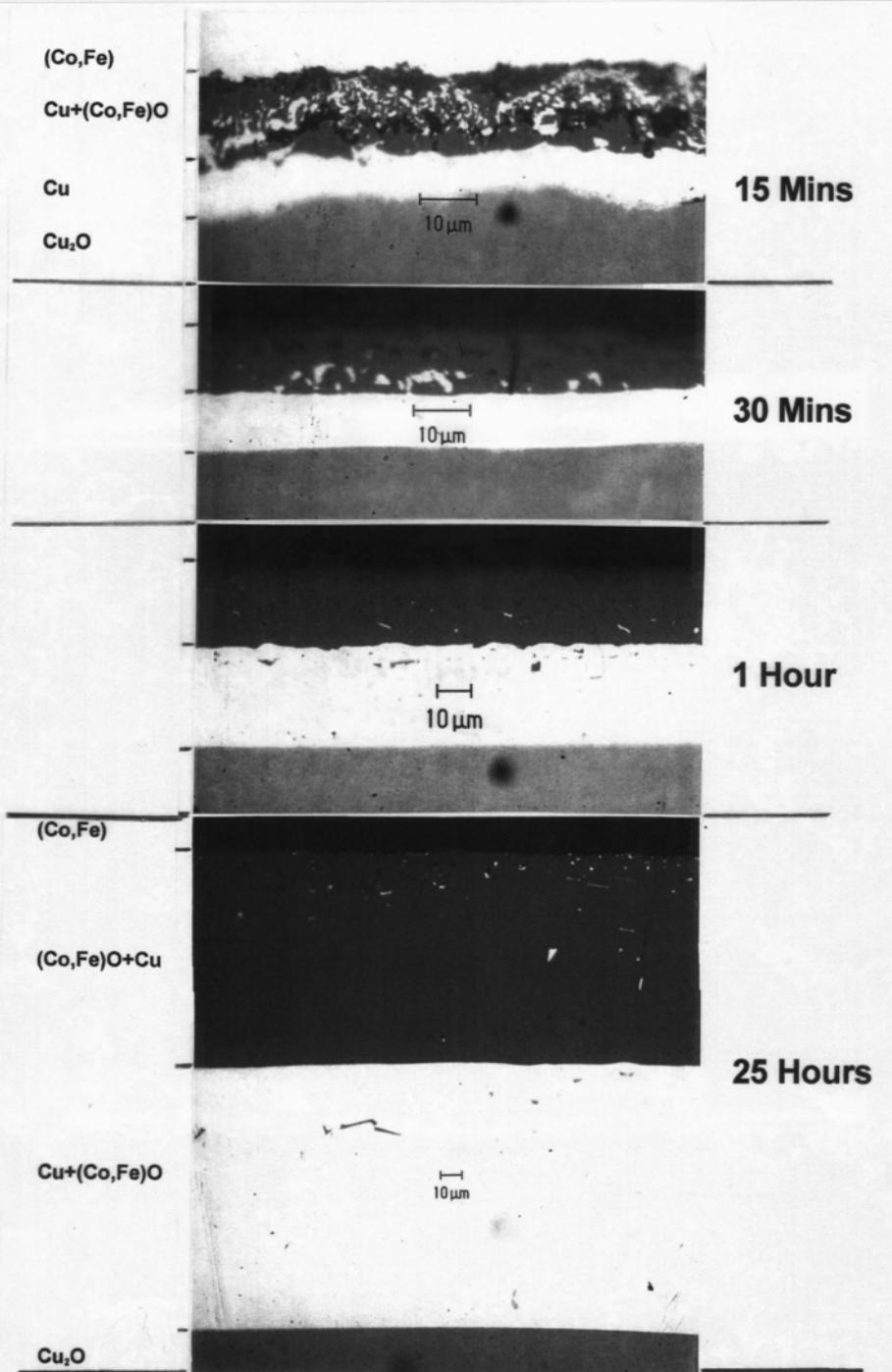


Fig.5. Evolution of the reactive interface morphology with time for the displacement reaction between Cu₂O and Co_{0.984}Fe_{0.016} at 1223 K.

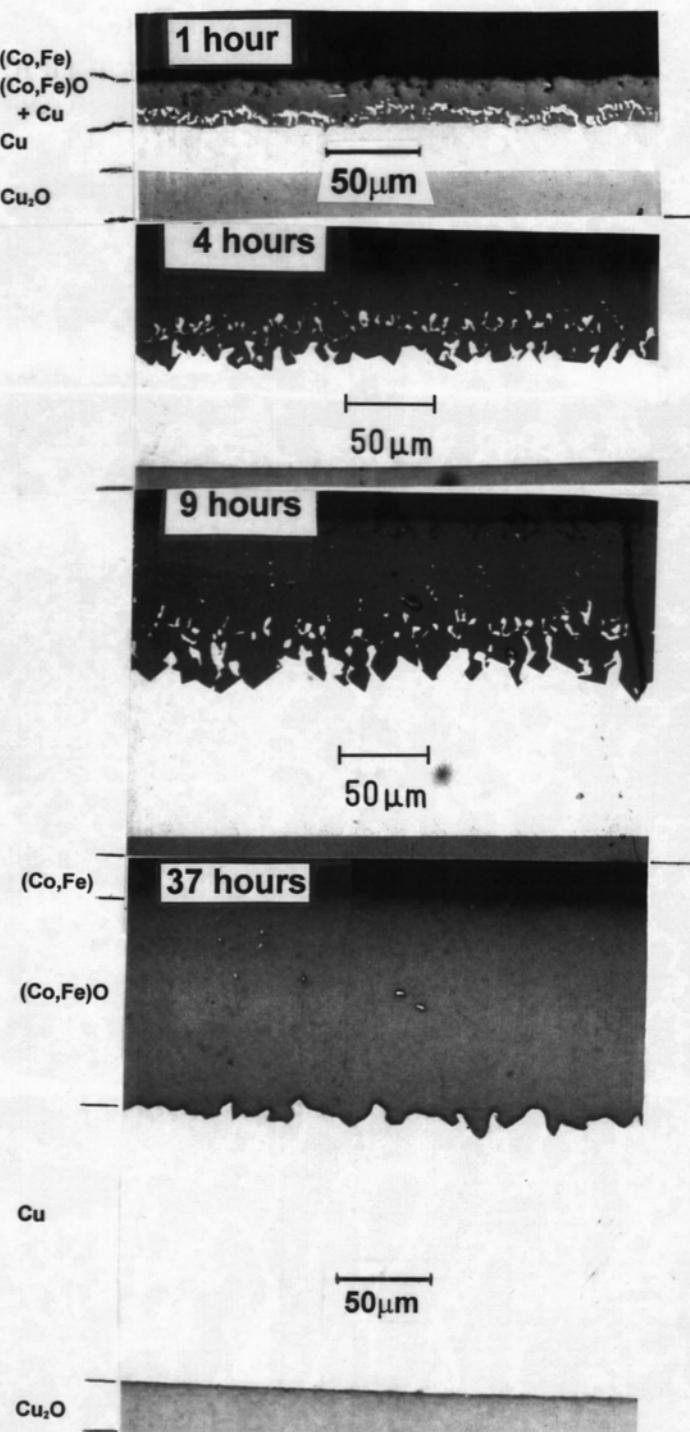


Fig.6. Reaction Zone Morphology between Cu_2O and $\text{Co}_{0.97}\text{Fe}_{0.03}$ as a function of time at 1223 K.

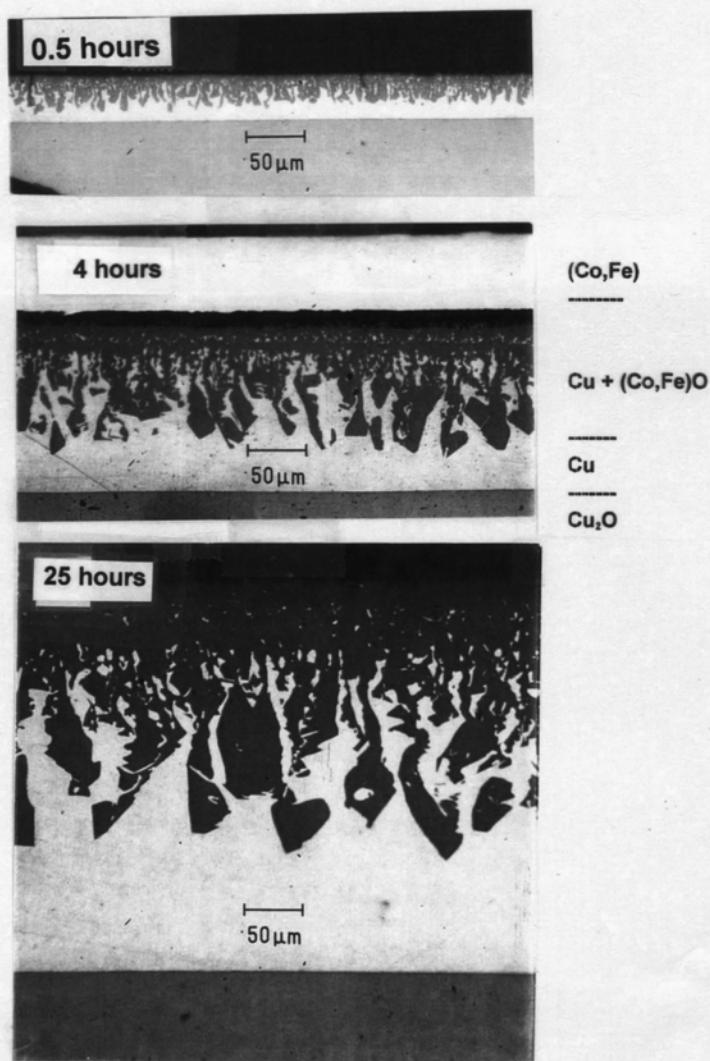
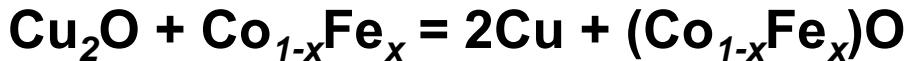


Fig. 7. Reaction Zone Morphology as a function of time for the reaction between Cu_2O and $\text{Co}_{0.955}\text{Fe}_{0.045}$.

Kinetics ($T = 1223$ K):



$x = 0, 0.015$ and $0.03 \rightarrow$ planar interface at long times.

$J_{\text{Co, Fe}}$ in $(\text{Co}_{1-x}\text{Fe}_x)\text{O}$ -- Rate limiting ?

Parabolic rate Constant for Cu phase, $k_p^{\text{Cu}}(x)$

X	k_p^{Cu} , m^2s^{-1} experimental from reaction	calculated from D_{Cation}	$k_p^{\text{Cu}}(x) / k_p^{\text{Cu}}(x=0)$ (experimental)
0	6.0×10^{-15}	# 8.5×10^{-15}	-----
0.015	6.6×10^{-14}	-----	11
0.03	1.1×10^{-13}	-----	18

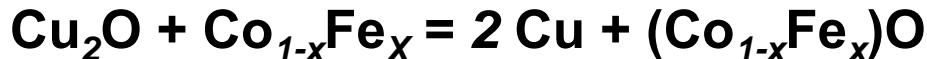
D^T_{Co} in CoO from Dieckmann, 1977.

Other Cation diffusion data in $(\text{Co},\text{Fe})\text{O}$ at 1473 K:

$\{\mathcal{D}_{\text{Co,Fe}}$ in $(\text{Co}_{0.984}\text{Fe}_{0.016})\text{O}\} / \{\mathcal{D}_{\text{Co}}$ in CoO} = 7 – 9
Hoshino, Peterson , 1985

$\{\mathcal{D}_{\text{Co,Fe}}$ in $(\text{Co}_{0.97}\text{Fe}_{0.03})\text{O}\} / \{\mathcal{D}_{\text{Co}}$ in CoO} = 21 – 25
Tinkler, Subramanian, Dieckmann, 1994

Transition in reactive interface Stability:



Experimental observation: (1223 K)

$x = 0.03 \Rightarrow$ stable, planar interface at long times

$x = 0.045 \Rightarrow$ non-planar interface at long times

$x = 0.03 + \varepsilon \Rightarrow$ stability transition ($\varepsilon = 0.005 - 0.01$)

$$k_p^{\text{Cu}} (x = 0.03) = 1.1 \times 10^{-13} \text{ m}^2\text{s}^{-1} \text{ (corresponds to } J_{\text{cation}}^{\max})$$

$$k_p^{\text{Cu}} (x = 0.03 + \varepsilon) = (1.1 + \delta) \times 10^{-13} \text{ m}^2\text{s}^{-1} \text{ (--- ditto ---)}$$

What is k_p^{Cu} maximum when $J_O(\text{Cu})$ is rate limiting ?

T = 1223 K

J_O

Cu_2O	$N_o^s(\text{Cu}) = 110 \text{ atomic ppm}$ Cu $N_o(\text{Cu}) = 0$ $D_O(\text{Cu}) = 2.3 \times 10^{-9} \text{ m}^2\text{s}^{-1}$
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$$k_p^{\text{Cu}} \text{ (maximum)} = 5.0 \times 10^{-13} \text{ m}^2\text{s}^{-1} \text{ (corresponds to } J_O^{\max}(\text{Cu})$$
$$= (1.1 + 3.9) \times 10^{-13} \text{ m}^2\text{s}^{-1}$$

$\downarrow \delta$

Summary:

Transition of interface stability occurs when:

J_O^{\max} (metal) $\approx J_{\text{cation}}^{\max}$ (oxide)
 > stable
 < unstable